

What Is Claimed Is:

1. A liquid crystal display device, comprising:
  - a transparent insulating substrate;
  - a gate line and a gate electrode on the transparent insulating substrate;
  - a gate insulating film, an active layer, an ohmic contact layer, source and drain electrodes, and a data line on the transparent insulating substrate;
  - a passivation film formed on the transparent insulating substrate including the source and drain electrodes and the data line;
  - a compensation film formed on the passivation film; and
  - a pixel electrode formed on at least the compensation film.
2. The device according to claim 1, wherein the pixel electrode includes ITO.
3. A method of fabricating a liquid crystal display device, comprising:
  - forming a gate line and a gate electrode on a transparent insulating substrate;
  - forming a gate insulating film, an active layer, an ohmic contact layer, source and drain electrodes, and a data line on the transparent insulating substrate;

forming a passivation film on the transparent insulating substrate including the source and drain electrodes and the gate line;  
forming a compensation film on at least the passivation film; and  
forming a pixel electrode on the compensation film.

4. The method according to claim 3, wherein the pixel electrode includes an ITO metal film.

5. A liquid crystal display device, comprising:

a transparent insulating substrate;  
a black matrix formed on the transparent insulating substrate;  
a color filter layer formed on an upper surface of the black matrix;  
a compensation film formed on the color filter layer; and  
a common electrode formed on the compensation film.

6. The device according to claim 5, further comprising an overcoat film having a planar upper surface formed between the color filter layer and the compensation film.

7. The device according to claim 5, wherein the common electrode includes ITO..

8. A method of fabricating a liquid crystal display, comprising:

forming a black matrix on a transparent insulating substrate;

forming a color filter layer on the black matrix;

forming a compensation film on an upper surface of the color filter layer;

and

forming a common electrode on the compensation film.

9. The method according to claim 8, further comprising forming an overcoat film after the forming of the color filter layer.

10. The method according to claim 8, wherein the common electrode includes ITO.

11. The method according to claim 8, wherein forming the color filter layer includes sequentially forming red, green, and blue color filter layers.

12. A liquid crystal display device, comprising:

a thin film transistor substrate;

a pixel electrode formed on the thin film transistor substrate;

a color filter substrate;

a common electrode formed on the color filter substrate;

a liquid crystal material formed between the thin film transistor substrate and the color filter substrate; and

a compensation film contacting at least one of the pixel electrode and the common electrode,

wherein the compensation film compensates for phase variations of light transmitted through the liquid crystal material.

13. The device according to claim 12, further comprising an overcoat film formed between compensation film and a color filter film on the color filter substrate.

14. The device according to claim 13, wherein the overcoat film is formed between red, green, and blue color filter layers of the color filter film.

15. The device according to claim 14, wherein the overcoat film contacts a black matrix formed between the red, green, and blue color filter layers.

16. The device according to claim 14, wherein the overcoat film contacts the red, green, and blue color filter layers.

17. A liquid crystal display device, comprising:

a first substrate including a plurality of pixel electrodes;

a second substrate including a common electrode, a color filter film,

and a black matrix;

a liquid crystal material formed between the first and second substrates;

an overcoat film on the color filter film; and

a compensation film formed beneath the common electrode.

18. The device according to claim 17, wherein an upper surface of the overcoat film is planar.

19. The device according to claim 17, wherein the overcoat film directly contacts the color filter film and the compensation film.

20. The device according to claim 19, wherein the overcoat film directly contacts the black matrix.

21. The device according to claim 17, wherein the overcoat film directly contacts the black matrix.